



PATENT

-1-

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Rosato et al. Application No.: 09/408,279 Filed: September 29, 1999 For: PROCESS AND SYSTEM FOR RINSING OF SEMICONDUCTOR SUBSTRATES	Group No.: -1746 Examiner: Kornakov APPLICANT'S INTERVIEW SUMMARY
---	---

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope, addressed to: Commissioner for Patents, Washington, DC 20231 on 12/10/01
Dated: 12/10/01 By: [Signature]
Name Janet Chan
STALLMAN & POLLOCK LLP

Commissioner for Patents
Washington, DC 20231

Sir:

Applicant's Interview Summary is being filed in response to the Examiner's Interview Summary (Paper No. 8), which was received by the undersigned on 21 November 2001.

The telephone interview took place on 3 October 2001 between Examiner Michael Kornakov and attorney Kathleen Frost. The outstanding Election/Restriction Requirement was discussed. Kathleen Frost requested clarification as to the Examiner's expectations in a response and Mr. Kornakov elaborated on his expectations. No specific election was made during the phone conference.

Respectfully submitted,

STALLMAN & POLLOCK LLP

RECEIVED
JAN 18 2002
TC 1700

By Kathleen A Frost
Kathleen A. Frost (Reg. No. 37,326)

Attorneys for Applicant(s)

121 Spear Street, Suite 290
San Francisco, CA 94105
Tel.: (415) 512-1312
Fax: (415) 512-1362

Atty Docket No.: SCP 6620